



Docket No.: M4065.0167/P167-A  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Kevin G. Donohoe et al.

Application No.: 10/779,843

Confirmation No.: 9432

Filed: February 18, 2004

Art Unit: 1765

For: ASPECT RATIO-CONTROLLED ETCH  
SELECTIVITY USING TIME MODULATED  
DC BIAS VOLTAGE

Examiner: K. C. Chen

**SUPPLEMENTAL AMENDMENT**

MS AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

**INTRODUCTORY COMMENTS**

This Amendment is being filed with a Request for Continued Examination (RCE), in response to the Advisory Action mailed on September 14, 2006.

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 6 of this paper.